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Notice of Allowability	Application No.	Applicant(s)
	09/965,803	TANAKA, KAZUHIRO
	Examiner	Art Unit
	Roberts Culbert	1763
The MAILING DATE of this communication apperall claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this or other appropriate communica GHTS. This application is subjection	application. If not included tion will be mailed in due course. <b>THIS</b>
1. This communication is responsive to the amendment filed :	<u>3/9/05</u> .	
2. ☑ The allowed claim(s) is/are <u>14 and 17-19</u> .		
3. The drawings filed on <u>01 October 2001</u> are accepted by the Examiner.		
4.		
Attachment(s)  1. Notice of References Cited (PTO-892)  2. Notice of Draftperson's Patent Drawing Review (PTO-948)  3. Information Disclosure Statements (PTO-1449 or PTO/SB/08 Paper No./Mail Date  4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	5. ☐ Notice of Informa 6. ☐ Interview Summa Paper No./Mail E 3), 7. ☐ Examiner's Amer	I Patent Application (PTO-152) ry (PTO-413), Date

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U.S. Patent and Trademark Office PTOL-37 (Rev. 1-04)

## Allowable Subject Matter

Claims 14 and 17-19 are allowed.

The following is an examiner's statement of reasons for allowance:

The prior art of record fails to teach or render obvious a method of chemical mechanical polishing comprising: supplying slurry including polishing particles to a polishing apparatus including a polisher and an object to be polished; measuring particle information including at least one of dispersion of the polishing particles and distribution of particle sizes of the polishing particles of the slurry that is directly supplied to the in the polishing apparatus; and controlling the polishing speed at which the object is being polished, based on the particle information by adjusting at least one of rotation speed of the polisher, rotation speed of the object, and force applied by the polisher to the object.

Applicant's arguments (pages 3-5) regarding the previous rejection of claim 14 based on Yueh alone have been considered, but are not persuasive. Yueh contains an enabling disclosure as would be recognized by one of ordinary skill in the art of chemical mechanical polishing and process control. However, the argument is most since applicant has amended claim 14 to include limitations of claim 16, which was previously rejected over Yueh in view of Shelton. The combination of Yueh and Shelton to arrive at the invention of amended claim 14 is deemed improper, since Shelton does not measure the dispersion or distribution of polishing particles of slurry that is directly supplied to the object, but instead detects for the presence of particles that are in the polished object.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Roberts Culbert whose telephone number is (571) 272-1433. The examiner can normally be reached on Monday-Friday (8:30-5:00).

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Parviz Hassanzadeh can be reached on (571) 272-1435. The fax phone number for the organization

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R. Culbert

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where this application or proceeding is assigned is 703-872-9306.

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